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## (54) PREPARATION FOR EXTERNAL USE FOR SKIN

(57)Abstract:

PROBLEM TO BE SOLVED: To obtain the subject preparation by including an extract from the mycelia of *Agaricus blazei* Murill and the mycelia culture filtrate and physiologically active substance(s) of animal origin to potentiate both moisturizing effect and epidermal fibroblast activating effect and have excellent effect for the prevention/improvement of skin aging symptoms.

SOLUTION: This preparation for external use for skin contacts (A) an extract from the mycelia of *Agaricus blazei* Murill (FERM 4731) (pref. at 0.0001-5 wt.%) and/or mycelia culture filtrate and (B) at least one kind of physiologically active substance of animal origin (e.g. a placenta or spleen extract from mammal such as human or cattle, soluble eggshell membrane protein, basic or acidic fibroblast growth factor, epithelial cell growth factor, nucleic acid, pref. at 0.0001-5 wt.%), and pref. further, a combination of (C) 0.0001-3 wt.% of an anti-inflammatory agent, (D) 0.001-10 wt.% of mucopolysaccharides (e.g. hyaluronic acid) and (E) 0.0001-5 wt.% of a 2-hydroxycarboxylic acid.

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